Impact of Sunlight and Humic Acid on the Deposition Kinetics of Aqueous Fullerene Nanoparticles (nC₆₀)

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ABSTRACT: Nanoparticle transport in natural settings is complex due to interactions with the surrounding environment. In this study, the impact of UVA irradiation and humic acid (HA) on deposition of aqueous fullerene nanoparticles (nC₆₀) on a silica surface as a surrogate for natural sediments was studied using packed column experiments and quartz crystal microbalance with dissipation monitoring under various solution conditions. Surface oxidation of nC₆₀ induced by UVA irradiation greatly retarded its deposition due to the increased negative surface charge and hydrophilicity. Dissolved HA, once adsorbed onto the nC₆₀ surface, also hindered its deposition mainly through steric hindrance forces. The extent of this effect depended on the properties and the amount of HA adsorbed, which is a function of ionic strength and HA concentration. HA has limited adsorption on UVA-irradiated nC₆₀ and is expected to play a less important role in its stability. HA immobilized onto the silica surface had a variable effect on nC₆₀ deposition, depending on the complex interplay of Derjaguin–Landau–Verwey–Overbeek (DLVO) and non-DLVO interactions such as electrostatic interaction, steric hindrance, and hydrogen bonding as well as HA molecular conformation. These results highlight the importance of environment-induced changes in nC₆₀ surface chemistry in its fate and transport in aquatic environments.

INTRODUCTION

Buckminsterfullerene (C₆₀) has drawn much attention due to its unique physicochemical properties such as antioxidative properties, photoactivity, hydrophobicity, the spherical cage structure, and high electron affinity, which could enable a wide range of potential applications including optics, cosmetics, and pharmaceuticals.¹ The current and potential use in consumer products and large-scale production of C₆₀ will inevitably lead to its release into the environment. Modeling studies predicted the concentrations of fullerenes at the order of magnitude of nanograms per liter to micrograms per liter in surface waters and micrograms per liter in wastewater treatment plant effluents.² Because C₆₀ as a molecule has extremely low solubility in water (1.3 × 10⁻⁸ ng/L ~ 7.96 ng/L),³,⁴ the nanosized colloidal particle of C₆₀ formed in the aqueous phase, usually referred to as nC₆₀, is considered a more environmentally relevant form of fullerene. Many studies showed that nC₆₀ can exert toxicity to various organisms such as bacteria, fish, and human cell lines,⁵–⁷ raising concerns regarding its potential impact to human and ecosystem health. Initial studies postulated that reactive oxygen species (ROS) generation is one of the major toxicity mechanisms involved.⁸ However, reports on the ROS generation of nC₆₀ were contradictory. Several studies reported minimal to no ROS production by aqueous nC₆₀ due to self-quenching.¹⁰,¹¹ Thus, it has been suggested that the toxicity of nC₆₀ stems from ROS-independent oxidative stress.¹²,¹³

Unlike conventional contaminants such as dissolved organic compounds and heavy metals, the fate and transport of nanoparticles are largely controlled by aggregation and deposition processes.¹⁴ A number of studies have investigated the transport of nC₆₀ in model porous media as well as natural soils using packed column experiments or quartz crystal microbalance with dissipation monitoring (QCM-D).¹⁵–²⁴ These studies suggest that the properties of nC₆₀ and the collector, solution chemistry, and hydrodynamic conditions are the major factors governing the deposition process. The deposition of nC₆₀ is qualitatively in good agreement with the classic DLVO theory and mostly happens in the primary minimum.¹⁹ However, the majority of past studies were carried out with pristine nC₆₀ in simple electrolyte solutions. Once released into the environment, nC₆₀ will interact with various environmental components, including sunlight and natural organic matter (NOM), which could alter its surface chemistry and consequently confound its environmental behavior. Ubiquitous in aquatic systems and soil, natural organic matter is a known key determinant of colloid transport. Dissolved humic acid has been shown to readily adsorb on nC₆₀ and enhance nC₆₀ colloidal stability in water.²⁵,²⁶ On the other
hand, the effect of surface-immobilized macromolecules (e.g., humic acid in organic-rich soil/sediment) on nC₆₀ deposition has been found to vary. Humic acid and alginate were found to retard nC₆₀ deposition through steric repulsion, while an extracellular polymeric substance (EPS) enhanced the deposition of nC₆₀.

Recent studies suggest that solar irradiation induced photochemical transformation could be an important fate process of nC₆₀ in aquatic environments.²⁷–³⁰ Hou and Jafvert reported surface oxidation and decomposition of nC₆₀ during long-term solar irradiation.²⁷,²⁸ Hwang and Li showed that nC₆₀ underwent surface oxidation under irradiation of UVA light, the major UV component in sunlight.³⁰ The oxygen-containing functional groups formed during UVA irradiation greatly hindered the aggregation of nC₆₀ in NaCl solutions due to the increased negative surface charge and hydrophilicity.²⁶ On the other hand, Ca²⁺ can interact with the functional groups and destabilize UVA-irradiated nC₆₀. However, the effect of solar irradiation on the deposition pattern of nC₆₀ has not been addressed in the literature.

In the present study, deposition of nC₆₀ under environmentally relevant conditions was investigated by introducing UVA irradiation and humic acid, in either dissolved or surface-immobilized form, into the experimental system. The main objective was to determine the role of nC₆₀ surface transformation (surface oxidation under sunlight and addition of humic acid) in its deposition behavior. nC₆₀ irradiated by UVA for varying periods of time was thoroughly characterized, and its deposition kinetics on bare and humic acid coated silica surfaces measured under different solution conditions was compared to that of pristine nC₆₀. nC₆₀ deposition kinetics was directly measured by QCM-D and compared to that determined by conventional packed column experiments. To our knowledge, this is the first study addressing the effect of solar irradiation on nC₆₀ deposition. Along with our earlier paper regarding the impact of sunlight and humic acid on nC₆₀ aggregation, findings from this study underscore the important role of solar irradiation in the environmental fate and transport of nC₆₀, suggesting that a better quantitative understanding of environment-induced changes in nC₆₀ surface chemistry is crucial to predicting its environmental transport and fate.

### MATERIALS AND METHODS

**Materials.** Sublimed C₆₀ powder (>99%) was purchased from Materials Electronics Research Corporation (Tucson, AZ). Suwannee River humic acid standard (II) (SRHA) and Elliott Soil humic acid (EHA) were purchased from the International Humic Substances Society (Atlanta, GA). Humic acid (HA) stock solutions were prepared by stirring the HA solutions in the dark for 24 h followed by filtration through 0.45 μm pore size nylon membrane filters (Whatman, Piscataway, NJ). The concentrations of HA stock solutions were determined using a high-sensitivity total organic carbon (TOC) analyzer (Shimadzu Scientific Instruments, Columbia, MD) based on the carbon content of SRHA (52.6%) and EHA (58.1%).³¹ Poly(ε-l-lysine) (PLL, P-1274), reagent-grade NaCl, and two types of pure silica sands, with particle size 0.5–10 μm (silica sand 1) and 5–15 nm (silica sand 2) were obtained from Sigma–Aldrich (St. Louis, MO). 4-(2-Hydroxyethyl)-1-piperazinethanesulfonic acid (HEPES) was purchased from Fisher Scientific (Pittsburgh, PA). All solutions were prepared with ultrapure water generated by an E-pure system (Barnstead, Dubuque, IA).

**Preparation of nC₆₀ Stock Suspension.** The aqueous nC₆₀ stock suspension was prepared using a direct sonication protocol. A total of 150 mg of pulverized C₆₀ powder was mixed with 200 mL of deionized water in a 500 mL glass beaker and sonicated at 100 W with a sonicating probe (Vibra-Cell VCVX 500, Sonics & Material, Newtown, CT) for 30 min in an ice bath. The resulting mixture was filtered through 2 μm pore size Millipore filters (Millipore, Billerica, MA) to remove large particles. All filters were washed with 10 mL of ultrapure water before use and replaced after 30 mL of filtrate was collected. The concentration of the resulting C₆₀ suspension was 11 mg/L as measured by TOC. It was diluted to 10 mg/L and stored in the dark at room temperature. The intensity based mean hydrodynamic diameter of nC₆₀ was determined by dynamic light scattering (DLS, Zen 3600 zetasizer Nano, Malvern, Worcestershire, UK) by phase analysis light scattering (PALS) at 25 °C. Samples were withdrawn on the 20th hour and 7th day and stored in the dark at room temperature before analysis. The surface oxygen content of nC₆₀ with different irradiation time was determined by X-ray photoelectron spectroscopy (XPS, PHI Quantera, Chanhassen, MN). To prepare samples for XPS analysis, 50 mL of sample suspension was filtered through a 0.1 μm membrane filter (Millipore, Billerica, MA) to collect nC₆₀ on the membrane surface. The solid cake was dried in a vacuum oven at −85 kPa and 100 °C for two days.

**nC₆₀ Aggregation Kinetics and Electrophoretic Mobility.** Particle size determines the diffusive mass transfer rate of colloidal particles to a surface and hence the deposition rate. nC₆₀ particle size during the deposition measurement was determined from aggregation kinetics measurements in the same solution chemistry (see the Supporting Information for details). The electrophoretic mobility of nC₆₀ and silica sands was measured in folded capillary cells (Malvern, Worcestershire, UK) by phase analysis light scattering (PALS) at 25 °C with at least five measurements per sample.

**Deposition Kinetics of nC₆₀.** The deposition kinetics of nC₆₀ on bare and humic acid (SRHA or EHA) coated silica surfaces was first studied using a QCM-D system (Q-Sense E4, BiolinScientific, Västra Frölunda, Sweden). The system is equipped with four measurement chambers each housing a 5 MHz silica-coated quartz crystal sensor (Batch 10384, Biolin Scientific, Västra Frölunda, Sweden). Before use, the silica-coated crystals were soaked in 2% SDS cleaning solution for 12 h and sonicated for 20 min. They were then copiously rinsed
with ultrapure water, dried with ultra high-purity N₂, and cleaned in an ozone/UV chamber (Bioforce Nanoscience, Inc., Ames, IA) for 30 min immediately prior to use. All the measurements were performed at a constant temperature of 25 °C and a flow rate of 0.1 mL/min, resulting in a laminar flow in the measurement chamber with a Reynolds number (Re) of 0.2. In each experiment, the electrolyte solution was first pumped through the measurement chamber until a stable baseline is achieved (i.e., the frequency signal drifts less than 1.8 Hz/h). For experiments involving dissolved humic acid, the background solution containing the electrolyte and humic acid was then introduced into the system for 20 min. Except for EHA in 100 mM NaCl, there was no humic acid adsorption on the silica surface at ionic strength up to 100 mM as reflected by the unchanged frequency. Predetermined amounts of NaCl, humic acid, and nC₆₀ stock solutions were mixed to form test solutions with 5 mg/L nC₆₀ in the solution chemistry of interest and an unadjusted pH of 6.0 ± 0.5. The resulting suspension was immediately pumped into the measurement chamber, allowing nC₆₀ to deposit on the silica-coated crystal surface. As the deposition took place, the increasing mass of nC₆₀ on the silica crystal surface hindered the vibration of the crystal and subsequently reduced the frequency. A viscoelastic deposited layer also dampened the sensor vibration, leading to energy dissipation.

The mass of a thin and rigid deposited layer on the silica crystal surface is related to the change of the frequency as described by the Sauerbrey equation:32,33

\[ \Delta m = -\frac{C \Delta f_n}{n} \]  

where \( \Delta m \) is the deposited mass, \( \Delta f_n \) is the change of frequency at overtone \( n \), and \( C \) is the crystal constant (17.7 ng/(Hz cm²)).

For a viscoelastic layer, the Voigt model is usually used to obtain the thickness or mass and viscoelastic properties of the layer.33 In our study, significant dissipation accompanied frequency decrease during nC₆₀ deposition (see representative data in the Supporting Information, Figure S1), suggesting a viscoelastic nC₆₀ layer. Both the frequency and the dissipation changed linearly with time during the initial deposition of nC₆₀ indicating continuous deposition on the clean crystal surface (i.e., no ripening or detachment). The Voigt model was employed to simultaneously fit the frequency and dissipation data at the 3rd, 5th, 7th, 9th, and 11th overtone to obtain a nC₆₀ deposition rate in terms of mass per unit time. The model calculated mass deposition rate correlated well with the initial slope of the frequency data (Supporting Information, Table S1 and Figure S2). Considering the limitations of the mass deposition rate calculation, for example, it assumes a homogeneous, uniform layer, and the mass calculated includes that of water in the layer, we chose to quantify the nC₆₀ deposition rate using the initial (200 s) slope of the frequency shift obtained at the third overtone \( \Delta f_3 \) is the most stable. In order to gain insight on the physicochemical interactions between nC₆₀ and the surface, nC₆₀ deposition rates were normalized by that measured under favorable deposition conditions to obtain the attachment efficiency \( \alpha \):

\[ \alpha = \frac{d\Delta f_f}{d\Delta f_i}_\text{av} \]  

where \( d\Delta f_f/dt \) and \( d\Delta f_i/dt \) are the initial slope of frequency shift measured at the third overtone in the solution of interest and that under favorable deposition conditions, respectively. In this study, the favorable deposition conditions were achieved by coating the silica crystal sensor with positively charged PLL.

Deposition of pristine nC₆₀ on bare sand was also examined using conventional packed column experiments to compare with the QCM-D results (see the Supporting Information for details on column experiments).

Precoating the Silica Surface with PLL and Humic Acid. To coat the silica crystal surface with PLL, the bare silica surface was first rinsed with a HEPES solution (10 mM HEPES, 100 mM NaCl). Then, the PLL coating solution (100 mg/L PLL, 10 mM HEPES, 100 mM NaCl) was introduced for 15 min, during which PLL adsorption reached equilibrium as suggested by the stabilized frequency. To study the deposition of nC₆₀ on a humic acid coated silica surface, a layer of humic acid was adsorbed on the PLL layer by flowing 10 mM NaCl followed by 10 mg/L humic acid in 10 mM NaCl for 40 min across the crystal surface. Finally, the PLL or humic acid coated surface was rinsed with the electrolyte solution used in the deposition measurement. Silica sand was used as a surrogate for the silica crystals to determine their surface potential. Humic acid coated silica sand was made by successively dispersing the sand in 100 mg/L PLL and 10 mg/L EHA solutions. The sand was separated from each solution by centrifugation (1000g for 5 min) and thoroughly washed with ultrapure water.

RESULTS AND DISCUSSION

nC₆₀ Deposition under Favorable Conditions. The favorable deposition rate of nC₆₀ as a function of NaCl concentration is presented in Figure 1. For each type of nC₆₀,

![Figure 1. Deposition rates of pristine, 20 h UVA-irradiated (20hUV) and 7 day UVA-irradiated (7DUV) nC₆₀ to PLL-coated silica crystal surface (favorable deposition condition) as a function of NaCl concentration. Error bars represent standard deviation.](Image)

the favorable deposition rate was constant at low ionic strength but decreased sharply as ionic strength increased. According to the aggregation data (Supporting Information, Table S2), when the nC₆₀ suspension entered the QCM-D measurement chamber (5 min after the nC₆₀ stock suspension was mixed with the NaCl solution), nC₆₀ nanoparticles were stable at low ionic strength (up to 10 and 150 mM for the pristine nC₆₀ and the 7 day UVA-irradiated nC₆₀ (7DUV nC₆₀), respectively) but aggregated at higher ionic strength. Peclet number (Pe), which represents the ratio of convective to diffusive mass transport, ranged from \( 5.9 \times 10^{-7} \) to \( 5.0 \times 10^{-5} \) in these deposition experiments, suggesting diffusive mass transport (see the
Supporting Information for Pe calculation). Therefore, the sharp decline of favorable deposition rate at higher ionic strength was attributed to the increase of particle size due to aggregation and the consequent decrease in diffusion coefficient as suggested by the Stokes−Einstein equation. Because the UVA irradiation did not change the initial particle size,26 the favorable deposition rates of all three nC60 were identical at low ionic strength that did not cause significant aggregation. The favorable deposition rate reached a plateau beyond a certain NaCl concentration. We hypothesize it is caused by the diffusion-limited nC60 aggregation at NaCl concentrations beyond the critical coagulation concentration (CCC), where the aggregation rate is independent of NaCl concentration.

**Effect of UVA Irradiation.** Figure 2 compares the deposition rate and attachment efficiency of pristine and UVA-irradiated nC60. Previous studies suggest the stability of pristine nC60 heavily depends on the synthesis protocol and resulting nanoparticle properties, especially particle size and surface charge.16,22,34 Nevertheless, deposition of pristine nC60 is generally susceptible to changes in ionic strength, with a critical deposition concentration of 18 mM NaCl (Figure 2a) in this work, lower than that previously reported for nC60 prepared by solvent exchange, 30 and 32 mM NaCl.16,35 The deposition rate of each nC60 was found to decrease at high ionic strength due to the decline of the mass transfer rate caused by concurrent aggregation of the nanoparticles (Figure 2b).

Figure 2a clearly shows that UVA irradiation remarkably enhanced the stability of nC60 against deposition, consistent with our previous finding showing that UVA irradiation enhanced the stability of nC60 against aggregation in NaCl solutions.26 The increased stability was mainly attributed to the surface oxidation and the resulting increase in negative surface potential and hydrophilicity. XPS analysis revealed a notable increase of mono-oxygenated carbon (C−O) and dioxygenated carbon (C=O or O−C−O) on an UVA-irradiated nC60 surface (Supporting Information, Figure S5), suggesting the introduction of oxygen-containing functional groups. The surface oxygen content of nC60 increased with increasing UVA irradiation time from 9.3 ± 0.3% at the pristine state to 11.3 ± 0.6% after 20 h and 14.2 ± 0.6% after 7 days of irradiation (Figure 3a). As a result, the negative surface charge increased with increasing irradiation time as indicated by the measured electrophoretic mobility (Figure 3b), consistent with their higher stability shown in Figure 2a. The 7DUV nC60 was also more negatively charged than previously reported,26 suggesting batch to batch variations of the irradiated samples. The stability of nC60 exhibits a systematic dependence on its surface oxygen content; the sample with higher surface oxygen content tends to be more stable. A similar relationship has been reported between the colloidal stability of multiwalled carbon nanotubes and its surface oxygen concentration.36,37

**Figure 2.** (a) Attachment efficiencies of pristine, 20hUV and 7DUV nC60 on a silica surface as a function of NaCl concentration. Error bars represent standard deviation. (b) Deposition rates of pristine, 20hUV and 7DUV nC60 on a silica surface as a function of NaCl concentration.

**Figure 3.** (a) Surface oxygen atomic concentration of nC60 as a function of UVA irradiation time as measured by XPS. Error bars represent standard deviation. (b) Electrophoretic mobility of pristine, 20hUV and 7DUV nC60 as a function of NaCl concentration.
between the 7DUV nC60 and the bare silica surface shows that the energy barrier disappears at 250 mM NaCl (Supporting Information, Table S3 and Figure S6). Such a discrepancy suggests that the surface oxygen functional groups can stabilize nC60 through non-DLVO forces. Lower than unity α values were also observed with UVA-irradiated nC60 in our previous study on nC60 aggregation.26 The decrease in attachment efficiency at high ionic strength has been reported in the deposition of bacteriophage MS2, noroviruses GI and GII, and polystyrene latex colloids on silica and glass surfaces.38-40 These results cannot be explained by the DLVO theory41,42 and were attributed to structural forces, likely the hydration force. The hydration force also seems to affect the deposition behavior of the pristine and 20 h UVA-irradiated (20hUV) nC60. The attachment efficiency of both was lower than expected at NaCl concentration between 80 and 100 mM. However, the hydration force was less significant for the pristine and 20hUV nC60 than the 7DUV nC60 because (1) UVA irradiation increased the surface hydrophilicity of nC60 and consequently enhanced the hydration force and (2) the hydration force is more pronounced at high ionic strength, where the surface hydrated counterions are more abundant.

The deposition kinetics of pristine nC60 was also characterized by packed column experiments. The seepage velocity was adjusted to match the flow velocity used in the QCM-D measurements (2 × 10−4 m/s). The Pe values in the packed column and QCM-D systems are 9.6 × 10−6 and 5.9 × 10−7, respectively, over the ionic strength range compared, suggesting diffusive transport in both systems (see the Supporting Information for details). Representative nC60 breakthrough curves are presented in Figure S4 of the Supporting Information. The calculated α values are compared to those determined by QCM-D in Figure 4. The attachment efficiency determined from the two systems, αcolumn and αQCM-D, agree with each other well, suggesting the relevance and applicability of QCM-D as an alternative for packed column experiments to study nC60 deposition behavior. The QCM-D method is less time-consuming and labor intensive; it also avoids heterogeneity in porous media grain size, porosity, and surface chemistry, which contribute to discrepancies between different works.

Effect of Dissolved Humic Acid. As a major component of NOM, humic acid can readily adsorb onto colloidal particles via hydrophobic interactions, alter their surface physicochemical properties, and consequently change their transport pattern. Various studies have reported that dissolved humic acid could retard deposition of various colloidal particles such as nC60, latex particles, carbon nanotubes, hematite, and titanium dioxide,46,43-47 mainly through the steric hindrance effect. Our previous study revealed that humic acid adsorbed on nC60 significantly enhanced the stability of nC60 against aggregation; with 1 mg/L SRHA, the CCC of the pristine nC60 rose from 84 to 331 mM NaCl,26 and there was no detectable change in particle size at 100 mM NaCl (the highest ionic strength used in deposition experiments with dissolved humic acid) for at least 5 min. Because the nC60 used in this work was prepared in the same way as our previous study, the particle size is assumed to remain unchanged in the presence of humic acid (at 1 and 5 mg/L) over the NaCl concentrations tested (5–100 mM).26 Thus, the favorable deposition rate measured in 5 mM NaCl solution in the absence of humic acid was used for the whole ionic strength range tested.

Adsorption of dissolved humic acid can affect nC60 deposition in two ways: (1) it hinders aggregation and hence enhances diffusive mass transfer; (2) it reduces the deposition attachment efficiency. As shown in Figure 5a, the deposition attachment efficiency was reduced by up to 1 order of magnitude in the presence of humic acid. The reduced deposition can be attributed to the change of nC60 surface potential and the steric repulsion from adsorbed humic acid. Adsorption experiments (see the Supporting Information for

![Figure 4](image_url)  
**Figure 4.** Correlation between attachment efficiencies of pristine nC60 deposition in the packed column system and QCM-D system at the same ionic strength. Error bars represent standard deviation. Dashed line indicates the perfect consistency.

![Figure 5](image_url)  
**Figure 5.** (a) Attachment efficiencies of pristine nC60 onto a silica surface as a function of NaCl concentration in the presence of dissolved SRHA or EHA. Error bars represent standard deviation. (b) Deposition rates of pristine nC60 onto a silica surface as a function of NaCl concentration in the presence of dissolved Suwannee River humic acid or Elliott Soil humic acid.
Effect of Surface-Immobilized Humic Acid. By using two pure silica sands (silica sands 1 and 2) as surrogates to the silica crystal surface, surface-immobilized humic acid was found to lower the negative surface potential of the silica crystal. As shown in Figure 6a, although the ζ potential of the two bare silica sands was drastically different, EHA-coated silica sands were similarly charged, suggesting that the surface potential of silica sands was dominated by the immobilized EHA macromolecules. The ζ potential of the bare silica crystal surface is −53 mV as measured by a SurPASS electrokinetic analyzer in 1 mM ionic strength, which is close to silica sand 1, −52 ± 2.2 mV.

The overall impact of dissolved humic acid on nC₆₀₀ deposition is the net effect of enhanced nC₆₀₀ mass transfer to the surface because of the smaller particle size and the reduced attachment efficiency (Figure 5b). The nC₆₀₀ deposition rate in the absence of humic acid initially increased with ionic strength due to the increase in attachment efficiency but declined at ionic strength greater than 20 mM due to nC₆₀₀ aggregation and hence decreased mass transfer. Dissolved humic acid reduced nC₆₀₀ deposition at low ionic strength, suggesting that the reduction in attachment efficiency due to steric hindrance outcompetes the enhanced mass transfer rate resulting from smaller particle sizes. At high ionic strength (e.g., 100 mM NaCl), however, the opposite occurred: nC₆₀₀ deposition rate in the absence of humic acid was much higher than that in the presence of humic acid, although the attachment efficiency of nC₆₀₀ is lower in the presence of humic acid (Figure 5a). This is attributed to the enhanced mass transfer rate of nC₆₀₀ in the presence of humic acid due to the smaller particle size. However, these results should not be simply interpreted as dissolved humic acid would enhance the deposition of nC₆₀₀ at high ionic strength, as nC₆₀₀ would undergo fast aggregation without humic acid and large nC₆₀₀ aggregates can be easily removed by straining in porous media, which is not reflected by the QCM-D measurement.
mV. Therefore, an EHA-coated silica crystal surface was assumed to have the same ζ potential as EHA-coated silica sand 1. This finding qualitatively agreed with an earlier study using crushed quartz sand as a surrogate for the silica crystal.50

The deposition of pristine nC60 on the EHA-coated silica surface was lower than that on the bare silica surface (Figure 6b), whereas the deposition of pristine nC60 on the SRHA-coated silica surface was similar to that on the bare silica surface except at 5 mM. This contradicts the DLVO calculation that shows notably lower energy barrier on the EHA-coated silica surface was similar to that on the bare silica surface except at 5 mM. This contradicts the DLVO calculation that shows notably lower energy barrier on the EHA-coated silica surface (Supporting Information, Table S3). The reduced deposition is attributed to steric hindrance by the immobilized macromolecules. However, neither of the mechanisms applied in this case. The 7DUV nC60 is more hydrophilic than the pristine nC60 as a result of surface oxidation; physical trapping, if any, is expected to also enhance the deposition of the pristine nC60 contradictory to our findings. Moreover, the effect of physical trapping will be largely suppressed at high ionic strength as the structure of humic acid becomes more compact. We hypothesize that three mechanisms are responsible for the enhanced attachment efficiency of the 7DUV nC60 on humic acid-coated silica surfaces: the diminished steric hindrance, the reduced collector surface potential, and hydrogen bonding. It has been shown that the structure and properties of immobilized macromolecules strongly depend on ionic strength.38,52 At high ionic strength (~60 mM), the steric hindrance diminishes as the conformation of humic acid becomes more compact.38,51 Thus, at the ionic strength we employed for measuring the 7DUV nC60 deposition kinetics, 40–200 mM, the steric hindrance force was likely not prominent. DLVO calculation suggests the presence of surface-immobilized humic acid reduces electrostatic repulsion, which partially offsets the effect of steric hindrance forces and gradually became the dominant effect with increasing ionic strength. This is consistent with our observation of both pristine and 7DUV nC60 deposition.

However, the deposition of the 7DUV nC60 on humic acid coated silica surfaces is relatively insensitive to ionic strength, suggesting the reduced electrostatic repulsion is not the sole mechanism for the enhanced deposition. Another likely mechanism involved is hydrogen bonding between the oxygen-containing groups on the 7DUV nC60 surface and the oxygen- and nitrogen-containing groups on surface-immobilized humic acid.

ASSOCIATED CONTENT

Supporting Information
Details of (1) QCM-D characterization of particle deposition kinetics, (2) determination of particle size during the deposition experiments, (3) packed column experiments, (4) XPS spectra of the pristine and 7DUV nC60 (5) DLVO interaction energy calculation, and (6) humic acid adsorption experiments. This material is available free of charge via the Internet at http://pubs.acs.org.

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Notes
The authors declare no competing financial interest.

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